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## **CLAIMS**

- 1. Process for silylating an acylamide, characterized in that an amide bearing a group Rf (perfluoroalkyl) is subjected to the action of a trialkylsilyl halide in the presence of a base whose halide, or hydrohalide, is insoluble in the medium and in the presence of a non-polar and non-hydrophilic solvent.
- Process according to claim 1,
   characterized in that the said solvent has a relative dielectric constant epsilon of not more than 5.
  - 3. Process according to claims 1 and 2, characterized in that the said solvent is such that water has a solubility therein of only 1% at most.
- 4. Process according to claims 1 to 3, characterized in that the said solvent is such that the reaction mixture fully dissolves the silylamide.
  - 5. Process according to claims 1 to 4, characterized in that the said solvent is a mixture.
- 6. Process according to claims 1 to 5, characterized in that the said solvent is chosen from hydrocarbons, which are advantageously aliphatic and preferably acyclic, silanes and fluorohydrocarbons.
- 7. Process according to claims 1 to 6,

  25 characterized in that the said solvent is chosen from those whose (starting) boiling point is, at atmospheric pressure, not more than about 100°C (advantageously two

significant figur s).

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- 8. Process according to claims 1 to.7, characterized in that the said solvent is chosen from those whose (starting) freezing point is, at atmospheric pressure, not more than 0°C, advantageously not more than -10°C.
  - 9. Process according to claims 1 to 8, characterized in that the said base is an organic base.
- 10. Process according to claims 1 to 9,

  10 characterized in that the said base is a non-silylable organic base.
  - 11. Process according to claims 1 to 10, characterized in that the said base is an organic base whose conjugate acid is not silylable.
- 12. Process according to claims 1 to 11, characterized in that the said base is a pnictine.
  - 13. Process according to claims 1 to 12, characterized in that the said base is an organic base which contains not more than about 10 (preferably two significant figures) atoms per basic function.
  - 14. Process according to claims 1 to 13, characterized in that the said base is an organic base which contains not more than about 8 (preferably two significant figures) atoms per basic function.
- 25 15. Process according to claims 1 to 14, characterized in that the said base is an amine.
  - 16. Process according to claims 1 to 15, characterized in that the said amide has the following

formula:

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 $Rf-CO-NH_{(2-x)}-[Si(R_1)(R_2)(R_3)]_x$ 

- with x representing 0 or 1;
- with R<sub>1</sub>, R<sub>2</sub> and R<sub>3</sub> being chosen from alkyl groups
   containing from 1 to 10 carbon atoms, optionally connected to one of the other groups R<sub>1</sub>, R<sub>2</sub> and R<sub>3</sub>;
   with Rf (perfluoroalkyl) meaning radicals of formula:

 $-(CX_2)_p-EWG$ 

where the identical or different groups X represent a fluorine or a radical of formula  $C_n F_{2n+1}$  where n is an integer not greater than 5, preferably not greater than 2;

where p represents an integer not greater than 2; where EWG represents an electron-withdrawing group whose functions, if any, are inert under the reaction conditions, advantageously fluorine or a perfluoro residue of formula  $C_nF_{2n+1}$  where n is an integer not greater than 8, advantageously not greater than 5; the total number of carbons in Rf is advantageously between 1 and 10, preferably between 1 and 5.

- 17. Process according to claims 1 to 16, characterized in that the said amide is an amide chosen from those of pentafluoropropanoic acid and those of trifluoroacetic acid.
- 25 18. Composition containing at least 95%, advantageously 98%, of N,O-bis(silyl)amides of pentafluoropropanoic acid or of trifluoroacetic acid.